

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants : Dureseti CHIDAMBARRAO, et al.

Group Art Unit: 2814

Appln. No. : 10/605,108

Examiner: PHAM, Long

Filed : September 9, 2003

For : METHOD FOR REDUCED N+ DIFFUSION IN STRAINED SI  
ON SI/GE SUBSTRATE**CHANGE OF CORRESPONDENCE ADDRESS**

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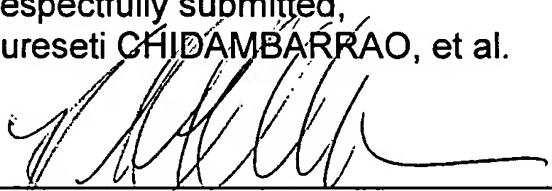
Sir:

Please direct future correspondence for the above identified application to the  
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Should there be any questions or comments, the Examiner is invited to contact  
the undersigned at the below listed telephone number.

Respectfully submitted,  
Dureseti CHIDAMBARRAO, et al.

  
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